

L Number	Hits	Search Text	DB	Time stamp
1	194	((ion adj beam) and (slot or slit) and elongated) and (magnetic or magnet)	USPAT; US-PGPUB; EPO; JPO	2002/11/19 15:59
2	25	((ion adj beam) and (slot or slit) and elongated) and (magnetic or magnet)) and (oblique or inclined)	USPAT; US-PGPUB; EPO; JPO	2002/11/19 16:10
-	872	(ion adj doping) and plasma	USPAT; US-PGPUB; EPO; JPO	2002/03/05 17:02
-	0	((ion adj doping) and plasma) and substrate	USPAT; US-PGPUB; EPO; JPO	2002/03/05 17:02
-	846	((ion adj doping) and plasma) and substrate	USPAT; US-PGPUB; EPO; JPO	2002/03/06 12:56
-	61	((ion adj doping) and plasma) and substrate) and orthogonal	USPAT; US-PGPUB; EPO; JPO	2002/03/05 17:04
-	5	((ion adj doping) and plasma) and substrate) and orthogonal) and ((extraction or acceleration) adj electrode)	USPAT; US-PGPUB; EPO; JPO	2002/03/05 17:07
-	12	((ion adj doping) and plasma) and substrate) and ((extraction or acceleration) adj electrode)	USPAT; US-PGPUB; EPO; JPO	2002/03/05 17:11
-	15	((ion adj doping) and plasma) and substrate) and ((extraction or acceleration) near4 electrode)	USPAT; US-PGPUB; EPO; JPO	2002/03/06 11:06
-	15	"5892235" "5837568" "42764774804852" "5696382" "5721687" "5767522"	USPAT; US-PGPUB; EPO; JPO	2002/03/06 09:51
-	501	((ion adj doping) and plasma) and substrate) and accelerati\$	USPAT; US-PGPUB; EPO; JPO	2002/03/06 10:02
-	19	((ion adj doping) and plasma) and substrate) and accelerati\$) and suppression	USPAT; US-PGPUB; EPO; JPO	2002/03/06 12:56
-	290	((ion adj doping) and plasma) and substrate) and accelerati\$) and phosphine	USPAT; US-PGPUB; EPO; JPO	2002/03/06 10:22
-	192	((ion adj doping) and plasma) and substrate) and accelerati\$) and phosphine) and diborane	USPAT; US-PGPUB; EPO; JPO	2002/03/06 10:22
-	5	((ion adj doping) and plasma) and substrate) and accelerati\$) and phosphine) and diborane) and decelerat\$	USPAT; US-PGPUB; EPO; JPO	2002/03/08 16:16
-	242	((ion adj doping) and plasma) and substrate) and implanting	USPAT; US-PGPUB; EPO; JPO	2002/03/08 10:26
-	3	((ion adj doping) and plasma) and substrate) and implanting) and (mass adj spectrometer)	USPAT; US-PGPUB; EPO; JPO	2002/03/08 16:04
-	37	((ion adj doping) and plasma) and substrate) and implanting) and slit	USPAT; US-PGPUB; EPO; JPO	2002/03/08 10:32
-	5	"5837568"	USPAT; US-PGPUB; EPO; JPO	2002/03/08 15:40
-	367	(ion adj beam) and (slot or slit) and elongated	USPAT; US-PGPUB; EPO; JPO	2002/11/19 15:54
-	142	((ion adj beam) and (slot or slit) and elongated) and (magnetic adj field)	USPAT; US-PGPUB; EPO; JPO	2002/11/19 14:51
-	65	((ion adj beam) and (slot or slit) and elongated) and (magnetic adj field)) and coil	USPAT; US-PGPUB; EPO; JPO	2002/11/19 14:51

-	25	(((((ion adj beam) and (slot or slit) and elongated) and (magnetic adj field)) and coil) and laser	USPAT; US-PGPUB; EPO; JPO	2002/11/19 14:58
-	1	(((((ion adj beam) and (slot or slit) and elongated) and (magnetic adj field)) and coil) and laser) and oblique	USPAT; US-PGPUB; EPO; JPO	2002/11/19 14:59
-	5	(((((ion adj beam) and (slot or slit) and elongated) and (magnetic adj field)) and coil) and oblique	USPAT; US-PGPUB; EPO; JPO	2002/11/19 15:19
-	9	((((ion adj beam) and (slot or slit) and elongated) and (magnetic adj field)) and oblique	USPAT; US-PGPUB; EPO; JPO	2002/11/19 15:43

L Number	Hits	Search Text	DB	Time stamp
1	367	(ion adj beam) and (slot or slit) and elongated	USPAT; US-PGPUB; EPO; JPO	2002/11/19 14:50
2	142	((ion adj beam) and (slot or slit) and elongated) and (magnetic adj field)	USPAT; US-PGPUB; EPO; JPO	2002/11/19 14:51
3	65	((((ion adj beam) and (slot or slit) and elongated) and (magnetic adj field)) and coil	USPAT; US-PGPUB; EPO; JPO	2002/11/19 14:51
4	25	((((ion adj beam) and (slot or slit) and elongated) and (magnetic adj field)) and coil) and laser	USPAT; US-PGPUB; EPO; JPO	2002/11/19 14:58
5	1	(((((ion adj beam) and (slot or slit) and elongated) and (magnetic adj field)) and coil) and laser) and oblique	USPAT; US-PGPUB; EPO; JPO	2002/11/19 14:59
6	5	(((((ion adj beam) and (slot or slit) and elongated) and (magnetic adj field)) and coil) and oblique	USPAT; US-PGPUB; EPO; JPO	2002/11/19 15:19
7	9	((((ion adj beam) and (slot or slit) and elongated) and (magnetic adj field)) and oblique	USPAT; US-PGPUB; EPO; JPO	2002/11/19 15:43
-	872	(ion adj doping) and plasma	USPAT; US-PGPUB; EPO; JPO	2002/03/05 17:02
-	0	((ion adj doping) and plasma) and substrate	USPAT; US-PGPUB; EPO; JPO	2002/03/05 17:02
-	846	((ion adj doping) and plasma) and substrate	USPAT; US-PGPUB; EPO; JPO	2002/03/06 12:56
-	61	((((ion adj doping) and plasma) and substrate) and orthogonal	USPAT; US-PGPUB; EPO; JPO	2002/03/05 17:04
-	5	(((((ion adj doping) and plasma) and substrate) and orthogonal) and ((extraction or acceleration) adj electrode)	USPAT; US-PGPUB; EPO; JPO	2002/03/05 17:07
-	12	((((ion adj doping) and plasma) and substrate) and ((extraction or acceleration) adj electrode)	USPAT; US-PGPUB; EPO; JPO	2002/03/05 17:11
-	15	(((((ion adj doping) and plasma) and substrate) and ((extraction or acceleration) near4 electrode)	USPAT; US-PGPUB; EPO; JPO	2002/03/06 11:06
-	15	"5892235" "5837568" "42764774804852" "5696382" "5721687" "5767522"	USPAT; US-PGPUB; EPO; JPO	2002/03/06 09:51
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-	19	(((((ion adj doping) and plasma) and substrate) and accelerati\$) and suppression	USPAT; US-PGPUB; EPO; JPO	2002/03/06 12:56
-	290	(((((ion adj doping) and plasma) and substrate) and accelerati\$) and phosphine	USPAT; US-PGPUB; EPO; JPO	2002/03/06 10:22
-	192	(((((ion adj doping) and plasma) and substrate) and accelerati\$) and phosphine) and diborane	USPAT; US-PGPUB; EPO; JPO	2002/03/06 10:22
-	5	(((((ion adj doping) and plasma) and substrate) and accelerati\$) and phosphine) and diborane) and decelerat\$	USPAT; US-PGPUB; EPO; JPO	2002/03/08 16:16
-	242	((((ion adj doping) and plasma) and substrate) and implanting	USPAT; US-PGPUB; EPO; JPO	2002/03/08 10:26
-	3	(((((ion adj doping) and plasma) and substrate) and implanting) and (mass adj spectrometer)	USPAT; US-PGPUB; EPO; JPO	2002/03/08 16:04

-	37	((((ion adj doping) and plasma) and substrate) and implanting) and slit	USPAT; US-PGPUB; EPO; JPO	2002/03/08 10:32
-	5	"5837568"	USPAT; US-PGPUB; EPO; JPO	2002/03/08 15:40